



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Gennari

Application No.: 10/716,266

Filed: November 17, 2003

Title: METHOD OF LOCATING AREAS IN AN
IMAGE SUCH AS A PHOTO MASK LAYOUT
THAT ARE SENSITIVE TO RESIDUAL
PROCESSING EFFECTS

Attorney Docket No.:
UCALP011X1/B02-005-3

Examiner: Unknown

Group: 2877

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the U.S. Postal Service with sufficient postage as first-class mail on 3/19/04 an envelope addressed to the Commissioner for Patents, P.O. Box 1450 Alexandria, VA 22313-1450.

Signed: 

Kristina Gomez

REQUEST FOR CORRECTED FILING RECEIPT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Enclosed is a copy of the Filing Receipt for the above-identified patent application. Please reprint the Filing Receipt as follows and mail the corrected copy to the undersigned.

In the Priority Data as Claimed by Applicant, CHANGE

"This application is a CIP of 10/241,242 09/10/2002" to

--This application is a CIP of 10/241,242 09/10/2002 AND claims priority to 60/322,381, filed 09/11/01--.

Since this is a Patent Office typographical error, no fee should be due. However, the Commissioner is authorized to charge any fees that may be due to Deposit Account 500388 (Order No. UCALP011X1).

Respectfully submitted,
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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/716,266	11/17/2003	2877	1126	UCALP011X1/B02-005-3	19	35	4

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CONFIRMATION NO. 6483

FILING RECEIPT



OC000000011625722

Date Mailed: 01/06/2004

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. **If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections, facsimile number 703-746-9195. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).**

Applicant(s)

Frank E. Gennari, Berkeley, CA;

Assignment For Published Patent Application

The Regents of the University of California, Oakland, CA;

Domestic Priority data as claimed by applicant

This application is a CIP of 10/241,242 09/10/2002

AND claims priority to 60/322,381, filed 09/11/01

Foreign Applications

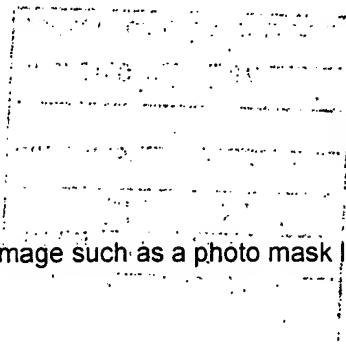
Projected Publication Date: To Be Determined - pending completion of Security Review

Non-Publication Request: No

Early Publication Request: No

Title

Method of locating areas in an image such as a photo mask layout that are sensitive to residual processing effects





Preliminary Class
356

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Title 37, Code of Federal Regulations, 5.11 & 5.15**

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